In re Patent Application of

Atty. Ref.: 900-473 **TAKENAKA**

Serial No. To be assigned Group: Unknown

Filed: September 5, 2003 Examiner: Unknown

For: MANUFACTURING METHOD FOR SEMICONDUCTOR SUBSTRATE, SEMICONDUCTOR SUBSTRATE AND SEMICONDUCTOR DEVICE

September 5, 2003

Commissioner for Patents P.O. Box 1450 Alexandria, VA 22313-1450

Sir:

INFORMATION DISCLOSURE STATEMENT

As suggested by 37 C.F.R. 1.97, the undersigned attorney brings to the attention of the Patent and Trademark Office the references listed on the attached form PTO-1449, a copy of each of which is enclosed. This is not to be construed as a representation that a search has been made or that no better prior art exists, or that a reference is relevant merely because cited.

The Examiner is requested to initial the attached form PTO-1449 and to return a copy of the initialed document to the undersigned as an indication that the attached references have been considered and made of record.

Respectfully submitted,

NIXON & VANDERHYE P.C.

By:

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(Use several sheets if necessary) TAKENAKA FILING DATE GROUP	
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U.S. PATENT DOCUMENTS	
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FOREIGN PATENT DOCUMENTS	
TRANSLAT DOCUMENT DATE COUNTRY CLASS SUBCLASS YES	10 101
	
OTHER DOCUMENTS (including Author, Title, Date, Pertinent pages, etc.) H. Trinkaus et al., "Strain relaxation mechanism for hydrogen-implanted Si _{1-x} Ge _x /Si(100) heterostructures", APPLIE	D
PHYSICS LETTERS, Vol. 76, No 24, 12 June 2000, pp. 3552-3554	ט
D. M. Follstaedt et al., "Cavity-dislocation interactions in Si-Ge and implications for heterostructure relaxation",	
APPLIED PHYSICS LETERS, 69 (14), 30 September 1996, pp. 2059-2061	
	
*Examiner Date Considered	
Examiner: Initial if reference considered, whether or not citation is in conformance with MPEP 609; Draw line through citation if not in conformance and not considered. Incopy of this form with next communication to application.	lude

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900-473

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